

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Cher Huan TAN § Confirmation No.: 4906
Moitreyee MUKHERJEE-ROY §
Pang Dow FOO § Group Art Unit: 2813
Serial No.: 10/025,085 ✓ § Examiner: T. S. Pham
Filed: December 19, 2001 ✓ § Atty. Docket No.: 2085-00600
For: Method For Preventing Photoresist § Client Ref. No.: IME-P002US
Poisoning In Semiconductor Fabrication §

PRELIMINARY AMENDMENT

Mail Stop 313(c)
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

Date: September 30, 2003

Sir:

The Examiner is respectfully requested to enter the following amendment prior to the calculation of fees and the initial examination of the present continuation above-identified patent application under 1.53(b) in which the parent case 10/025,085 survives.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.

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Mallari

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